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| <b>Search Notes</b><br><br> | <b>Application/Control No.</b><br><br>10591824 | <b>Applicant(s)/Patent Under Reexamination</b><br><br>CHAN ET AL. |
|  | <b>Examiner</b><br><br>SUCHIRA PANDE           | <b>Art Unit</b><br><br>1637                                       |

| SEARCHED |          |      |          |
|----------|----------|------|----------|
| Class    | Subclass | Date | Examiner |
|          |          |      |          |

| SEARCH NOTES   |           |          |
|--|-----------|----------|
| Search Notes   | Date      | Examiner |
| Google search  | June 2009 | SP       |
| PALM Inventor name search  | July 2009 | SP       |
| East Search  | July 2009 | SP       |
| Pubmed search  | July 2009 | SP       |
| SPEs Gary Benzion, Peter Paras and Chris Low were consulted re "subject of chinese decent" phrase in claims. Use of this phrase makes this a SAWs case. It was decided that 112 2nd should be done as we do not know how much chinese does one have to be to qualify and how to determine that requisite percentage? | July 2009 | SP       |

| INTERFERENCE SEARCH |          |      |          |
|---------------------|----------|------|----------|
| Class               | Subclass | Date | Examiner |
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